

**EAST Search History****EAST Search History (Prior Art)**

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	46	((el electr electroluminescen\$2) and electrode and insulating and sealant).clm.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2010/01/18 11:18
S1	1	2002-221911	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/29 00:34
S2	132	(kijima and yasunori)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/04 19:10
S3	120	(kijima and yasunori).in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/04 19:10
S4	32	S2 and (display and device) and resin	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/04 19:14
S5	0	S4 and "015424"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/04 19:14
S6	0	S5 and sealing	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/04 19:15
S7	29	S4 and sealing	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/04 19:15

S8	22	S7 and substrate and film	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/04 19:15
S9	15	S8 and mechanism	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/04 20:28
S10	232	313/506.ccls. and @ad<"20030912" and (pattern near2 layer)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/04 20:49
S11	233	(el electroluminescen\$2). clm. and ((barrier adj layer) with (water vapor gas))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/04 20:57
S12	48	S11 and @ad<"20030912"	US-PGPUB	OR	ON	2007/01/04 20:51
S13	3777	(el electroluminescen\$2). clm. and (thickness with substrate)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/04 20:58
S14	875	S13 and @ad<"20030912"	US-PGPUB	OR	ON	2007/01/04 20:58
S15	1082	(el electroluminescen\$2). clm. and (thickness near3 substrate) and @ad<"20030912"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/04 20:59
S16	407	(el electroluminescen\$2). clm. and (thickness near3 substrate) and @ad<"20030912"	US-PGPUB	OR	ON	2007/01/04 20:59
S17	83	(el electroluminescen\$2). clm. and (thickness near3 substrate) and (thickness near3 organic) and @ad<"20030912"	US-PGPUB	OR	ON	2007/01/04 21:05
S18	0	(el electroluminescen\$2). clm. and ((thickness near3 substrate) same mu) and ((thickness near3 el) same mu) and @ad<"20030912"	US-PGPUB	OR	ON	2007/01/04 21:01

S19	1	(el electroluminescen\$2). clm. and ((thickness near3 substrate) same mu) and ((thickness near3 el)) and @ad<"20030912"	US-PGPUB	OR	ON	2007/01/04 21:03
S20	1	10/527502	US-PGPUB	OR	ON	2007/01/04 21:03
S21	132	(el electroluminescen\$2). clm. and (thickness near3 substrate) and (thickness near3 (el electroluminescen \$2 organic)) and @ad<"20030912"	US-PGPUB	OR	ON	2007/09/29 00:57
S22	2	"20040201027".pn.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/09/29 00:35
S23	71	(el electroluminescen\$2). clm. and ((barrier near2 layer) with (water vapor gas)) and @ad<"20020913"	US-PGPUB; USPAT	OR	ON	2007/09/29 01:07
S24	168	(el electroluminescen\$2). clm. and ((barrier) with (water gas)) and @ad<"20020913"	US-PGPUB; USPAT	OR	ON	2007/09/29 01:21
S25	184	(el electroluminescen\$2). clm. and (light with transparent with pattern) and @ad<"20020913"	US-PGPUB; USPAT	OR	ON	2007/09/29 01:22
S26	2271	313/498-512.ccls. and (el electro electroluminescen \$2).clm. and @ad<"20020913"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/13 03:02
S27	912	S26 and pattern	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/13 03:03
S28	63	S26 and ((patterned pattern) with (insulation insulating)).clm.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/13 03:03

S29	591	S26 and (thickness).clm.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/13 03:51
S30	792	S26 and (thickness with ((electrode anode cathode) and substrate))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/13 03:52
S31	305	S26 and (thickness near4 ((electrode anode cathode) and substrate))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/13 03:52
S32	8	S26 and (thickness near4 ((electrode anode cathode) and substrate and (cover sealant encapsulat)))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/13 03:55
S33	2	2002-221911	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/13 04:16
S34	153	(kijima and yasunori)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/13 04:16
S35	136	(kijima and yasunori).in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/13 04:16
S36	39	S34 and (display and device) and resin	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/13 04:16
S37	0	S36 and "015424"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/13 04:16

S38	0	S37 and sealing	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/13 04:16
S39	35	S36 and sealing	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/13 04:16
S40	28	S39 and substrate and film	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/13 04:16
S41	19	S40 and mechanism	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/13 04:16
S42	240	313/506.ccls. and @ad<"20030912" and (pattern near2 layer)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/13 04:16
S43	336	(el electroluminescen\$2). clm. and ((barrier adj layer) with (water vapor gas))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/13 04:16
S44	48	S43 and @ad<"20030912"	US-PGPUB	OR	ON	2008/06/13 04:16
S45	4731	(el electroluminescen\$2). clm. and (thickness with substrate)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/13 04:16
S46	876	S45 and @ad<"20030912"	US-PGPUB	OR	ON	2008/06/13 04:16
S47	1124	(el electroluminescen\$2). clm. and (thickness near3 substrate) and @ad<"20030912"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/13 04:16
S48	408	(el electroluminescen\$2). clm. and (thickness near3 substrate) and @ad<"20030912"	US-PGPUB	OR	ON	2008/06/13 04:16

S49	84	(el electroluminescen\$2). clm. and (thickness near3 substrate) and (thickness near3 organic) and @ad<"20030912"	US-PGPUB	OR	ON	2008/06/13 04:16
S50	0	(el electroluminescen\$2). clm. and ((thickness near3 substrate) same mu) and ((thickness near3 el) same mu) and @ad<"20030912"	US-PGPUB	OR	ON	2008/06/13 04:16
S51	1	(el electroluminescen\$2). clm. and ((thickness near3 substrate) same mu) and ((thickness near3 el)) and @ad<"20030912"	US-PGPUB	OR	ON	2008/06/13 04:16
S52	1	10/527502	US-PGPUB	OR	ON	2008/06/13 04:16
S53	133	(el electroluminescen\$2). clm. and (thickness near3 substrate) and (thickness near3 (el electroluminescen \$2 organic)) and @ad<"20030912"	US-PGPUB	OR	ON	2008/06/13 04:16
S54	2	"20040201027".pn.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/06/13 04:16
S55	71	(el electroluminescen\$2). clm. and ((barrier near2 layer) with (water vapor gas)) and @ad<"20020913"	US-PGPUB; USPAT	OR	ON	2008/06/13 04:16
S56	169	(el electroluminescen\$2). clm. and ((barrier) with (water gas)) and @ad<"20020913"	US-PGPUB; USPAT	OR	ON	2008/06/13 04:16
S57	184	(el electroluminescen\$2). clm. and (light with transparent with pattern) and @ad<"20020913"	US-PGPUB; USPAT	OR	ON	2008/06/13 04:16
S58	2	"20030038595"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/01/17 13:50

S59	3650	((organic near2 (el electro electroluminescen\$2)) oeld oled).clm. and (insulat \$3 with (electrode anode cathode))	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/05/10 22:39
S60	1772	((organic near2 (el electro electroluminescen\$2)) oeld oled).clm. and (insulat \$3 with (electrode anode cathode) with between)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/05/10 22:40
S61	1	(yamazaki).in. and (el electroluminescen\$2).clm. and (insulation adj layer). clm.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/05/10 22:42
S62	70	(yamazaki).in. and (el electroluminescen\$2).clm. and (insulat\$3 adj layer). clm.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/05/10 22:42
S63	19	(yamazaki and shunpei).in. and (el electroluminescen \$2).clm. and (insulat\$3 adj layer).clm. and nitrogen. clm.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/05/10 22:45
S64	45	(el electroluminescen\$2). clm. and (insulat\$3 adj layer).clm. and nitrogen. clm.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/05/10 22:46
S65	2	10/353976	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/05/10 22:47

**EAST Search History (Interference)**

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L2	46	((el electr electroluminescen \$2) and electrode and insulating and sealant).clm.	US-PGPUB; USPAT; UPAD	OR	ON	2010/01/18 11:19

1/18/2010 11:20:16 AM

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